

## Supporting Information

# From Growth Surface to Device Interface: Preserving Metallic Fe under Monolayer Hexagonal Boron Nitride

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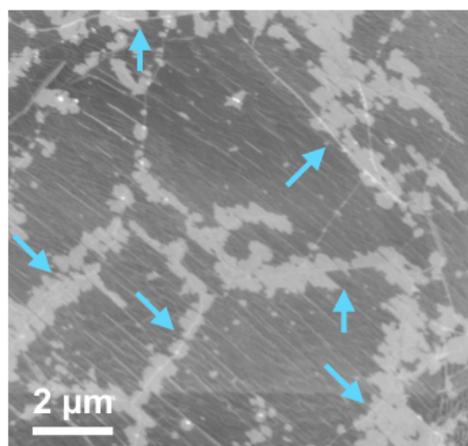
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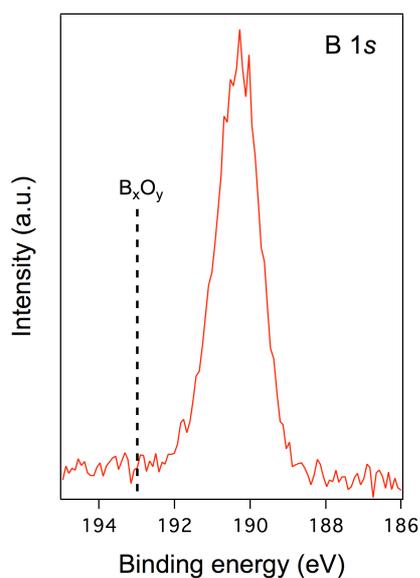
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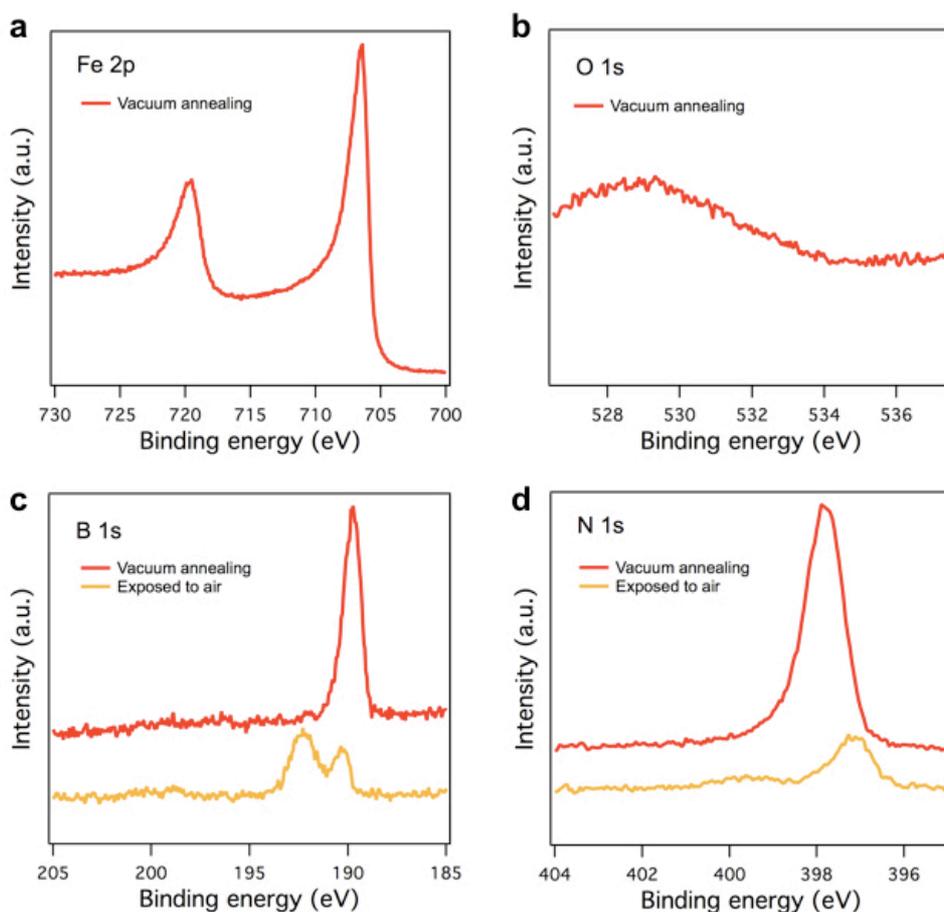
# Equal contribution



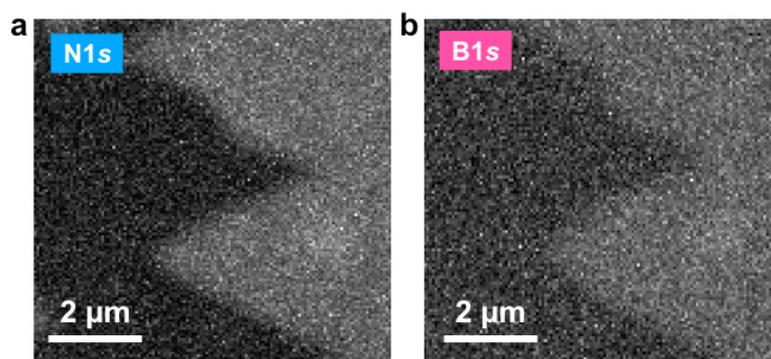
**Figure S1.** Higher magnification SEM image of h-BN film on Fe substrate after 1 day of air exposure (corresponding to Figure 1e) showing the bright contrast channels where oxidation of the underlying Fe proceeds more rapidly than in other regions.



**Figure S2.** XP spectrum of the B 1s core level for h-BN domains on Fe foil exposed to air for ~40 hours, showing the monolayer h-BN peak centred at 190.2 eV. The absence of a signal at ~193 eV (dotted line), which is typically assigned to boron oxide species,<sup>1</sup> demonstrates that the h-BN lattice does not undergo a significant degradation during room temperature air exposure. The spectrum is collected at a photon energy,  $E_{\text{photon}}$ , of 912 eV using the setup available at the Escamicroscopy beamline of Elettra synchrotron facility (Trieste, Italy).



**Figure S3.** XP spectra of h-BN domains on Fe foil during vacuum annealing at  $\sim 600$  °C using the (a) Fe 2*p* and the (b) O 1*s* core level energies, demonstrating the previously oxidized Fe has been reduced and there is a corresponding decrease in the oxygen content. XP spectra of the (c) B 1*s* and (d) N 1*s* core level energies acquired on the same sample during vacuum annealing and after subsequent exposure to ambient air. The Fe 2*p*, O 1*s*, B 1*s* and N 1*s* spectra are collected at photon energies,  $E_{\text{photon}}$ , of 920 eV, 680 eV, 400 eV and 620 eV respectively. All binding energies are referenced to measured Fermi edges.



**Figure S4.** SPEM chemical maps (i.e. topography removed) from the region enclosed within the red dotted square in Figure 4a, using the **(a)** N 1s and **(b)** B 1s core level energy. The B 1s and N 1s maps are collected at photon energies,  $E_{\text{photon}}$ , of 912 eV and 704.5 eV respectively.

## References

- (1) Müller, F.; Hüfner, S.; Sachdev, H. Epitaxial Growth of Boron Nitride on a Rh(111) Multilayer System: Formation and Fine Tuning of a BN-Nanomesh. *Surf. Sci.* **2009**, *603*, 425–432.